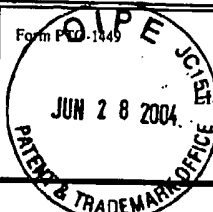
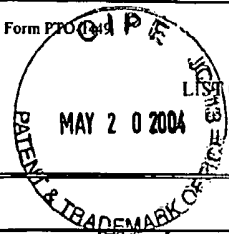
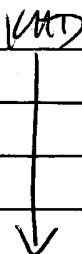
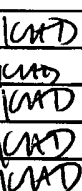

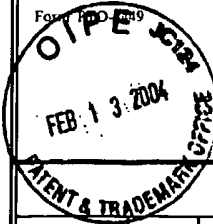


Form PTO-1449		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTY. DOCKET NO. M122-1694		SERIAL NO. 09/885,393		
 LIST OF ART CITED BY APPLICANT (Use several sheets if necessary)				APPLICANT Richard Holscher et al.				
				FILING DATE June 19, 2001		GROUP 1756		
U.S. PATENT DOCUMENTS								
*Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate	
KAD	AA	6,638,875 B2	10/03	Han et al.	438	725		
	AB	6,720,247 B2	04/04	Kirkpatrick et al.	438	622		
	AC	6,723,631 B2	04/04	Noguchi et al.	438	618		
	AD	6,627,535	09/03	MacNeil et al.	438	634		
	AE	5,543,741	01/97	Ikeda	429	579		
	AF	2003/0077916 A1	04/03	Xu et al.	438	778		
	AG	2003/0207594 A1	11/03	Catabay et al.	438	778		
KMD	AH	2004/0071878 A1	04/04	Schuhmacher et al.	427	255.28		
	AI							
	AJ							
	AK							
	AL							
FOREIGN PATENT DOCUMENTS								
		Document Number	Date	Country	Class	Subclass	Translation	
							Yes	No
	AM							
	AN							
	AO							
	AP							
	AQ							
OTHER REFERENCES (including Author, Title, Date, Pertinent Pages, Etc.)								
	AR							
	AS							
	AT							
EXAMINER				DATE CONSIDERED				
K. Duda				8-30-04				
*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.								

Form PTO-101 		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTY. DOCKET NO. M122-1694		SERIAL NO. 09/885,393		
LIST OF ART CITED BY APPLICANT (Use several sheets if necessary)				APPLICANT Richard Holscher et al.				
				FILING DATE June 19, 2001		GROUP 1756		
U.S. PATENT DOCUMENTS								
*Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate	
	AA	4,971,655	11/20/1990	Stefano et al.	156	659		
	AB	6,153,504	11/28/2000	Shields et al.	438	613		
	AC	6,087,064	07/11/00	Lin et al.	430	270.1		
	AD	5,986,318	11/16/99	Kim et al.	257	437		
	AE	6,498,084 B2	12/24/02	Bergemont	438	593		
	AF	5,036,383	07/30/91	Mori	357	71		
	AG							
	AH							
	AI							
	AL							
FOREIGN PATENT DOCUMENTS								
		Document Number	Date	Country	Class	Subclass	Translation	
							Yes	No
	AM	08-045926	16/02/1996	Japan (Abstract)	—	—		
	AN	10-163083	19/06/1998	Japan	—	—	x	
	AO	JP8051058	20/02/96	Japan (Abstract)	—	—		
	AP	JP63316476	23/12/88	Japan (Abstract)	—	—		
	AQ	JP8078322	22/03/96	Japan (Abstract)	—	—		
OTHER REFERENCES (including Author, Title, Date, Pertinent Pages, Etc.)								
	AR		Wolf, S., "Silicon Processing for the VLSI Era", Vol. 3; pg. 635					
	AS							
	AT							
EXAMINER <b>K. Duda</b>				DATE CONSIDERED <b>8-30-04</b>				
*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.								

Form PTO-609 		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTY. DOCKET NO. M122-1694		SERIAL NO. 09/885,393	
LIST OF ART CITED BY APPLICANT (Use several sheets if necessary)				APPLICANT Richard Holscher et al.			
				FILING DATE June 19, 2001		GROUP 1756	
U.S. PATENT DOCUMENTS							
*Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate
	AA						
	AB						
	AC						
	AD						
	AE						
	AF						
	AG						
	AH						
	AI						
	AJ						
	AK						
	AL						
FOREIGN PATENT DOCUMENTS							
		Document Number	Date	Country	Class	Subclass	Translation
							Yes No
KMD	AM	JP8046186	02/16/96	Japan	—	—	x
KMD	AN	JP07201716A	08/04/95	Japan	—	—	x
	AO						
	AP						
	AQ						
OTHER REFERENCES (including Author, Title, Date, Pertinent Pages, Etc.)							
	AR						
	AS						
	AT						
EXAMINER				DATE CONSIDERED			
K. Duda				8-30-04			
*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.							

EL 979978909